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# Structural and optical properties of Zinc oxide-Reduced Graphene oxide nanocomposite thin films prepared by hydrothermal method.

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**Abstract:** In this work, we report the synthesis and characterization of Zinc oxide– Reduced Graphene oxide Nanocomposite thin films prepared by hydrothermal route. The synthesized films were characterized by Scanning electron microscope (SEM), X-Ray Diffraction (XRD) and UV-VIS Spectrophotometer for morphology, structural and optical properties. The functional group analysis of Graphene Oxide was carried out using FTIR spectroscopy. The influence of amount of GO in the reaction medium on the surface morphology, structural and optical properties were investigated. It was found that the amount of GO showed negligible change in the morphology of the thin films but the bandgap changed from 3.3eV to 3eV. **Keywords:** Nanocomposite thin films, Zinc Oxide, Graphene Oxide, hydrothermal method.

# Introduction

Zinc Oxide (ZnO), a wide band gap (3.37eV) and with large exciton binding energy (60meV)<sup>1</sup> is a promising material for various applications such as gas sensors<sup>2</sup>, solar cells<sup>3</sup>, UV sensor<sup>4</sup>. By addition of additives like GO showed enhanced properties in applications like gas sensor<sup>5</sup> and UV sensor<sup>6</sup>. Graphene, a two dimensional honeycomb lattice structure with zero band gap has unique electrical, thermal and mechanical properties<sup>7-8</sup>finds potential applications in solar cells<sup>9-11</sup>, drug delivery<sup>12</sup> and sensors<sup>13</sup>. Various deposition methods such as chemical vapor deposition<sup>14-15</sup> spray deposition<sup>16-17</sup> and spin coating<sup>18-19</sup> have been employed to deposit ZnO-RGO films over various substrates. Several works have been reported about ZnO–RGO nanocomposites such as MajidAzarang et.al synthesisedZnO/RGO nanocomposites and investigated the effect of GO concentration on photo current generation<sup>20</sup>. N.M.Huang et.al prepared ZnOnanorods decorated RGO nanocomposites and studied the effect of GO concentration on morphology, structural and optical properties<sup>21</sup>. U. Alver et.al has studied optical and structural properties of ZnOnanorods grown on graphene oxide and reduced graphene oxide by hydrothermal process<sup>22</sup>.

In the present work a simple sol-gel technique was used to synthesize ZnO nanoparticles and GO was prepared by Hummers method. The ZnO-RGOnanocomposite thin films were prepared on glass substrate by spin coating technique and the prepared thin films were immersed vertically in aqueous growth solution containing zinc nitrate hydrate (Zn (NO<sub>3</sub>)<sub>2</sub>·5H<sub>2</sub>O), hexamethylenetetramine (C<sub>6</sub>H<sub>12</sub>N<sub>4</sub>) and GO inside the Teflon – lined autoclave. The effect of different concentration of GO on morphology, structural and optical properties of ZnO-RGO nanocomposite thin films were investigated.

# **Experimental section**

# **Preparation of Graphene Oxide:**

Graphene oxide (GO) was synthesized from graphite powder by Hummers method. Briefly, 2 g graphite powder and 1g NaNO<sub>3</sub> were mixed with 46 mL of concentrated  $H_2SO_4$ . Next, 6 g of KMnO<sub>4</sub> was added under ice bath to prevent the temperature from exceeding 20°C, after which the mixture was stirred and held at 35°C for 30min. Then, 92mL of deionized water was slowly added into the system. After stirring for 15 min, 80mL of warm water was added. To reduce excess KMnO<sub>4</sub>, a proper amount of 3%  $H_2O_2$  aqueous solution was dropped into the mixture until no bubbles were observed. The mixture was then centrifuged to remove the residual impurities. The Graphitic oxidewas obtained by dehydration at 60°C in air. The GO is obtained by Graphitic oxide dispersed into water by ultra sonication and centrifugation for half an hour to remove any unexfoliated GO.

#### Seed layer Deposition

The seed layer was prepared by low cost sol gel technique. Prior to the seed layer deposition, the glass substrate (2" \*2") were cleaned using chromic acid solution and then rinsed with de-ionized (DI) water. Further, the glass substrates were ultrasonically cleaned using acetone for 10 minutes. The cleaned glass substrates were then used for the deposition of ZnO-GO seed layer using spin coating technique. 0.9M Zinc Acetate dehydrate (Zn(CH<sub>3</sub>COO)<sub>2</sub>.H<sub>2</sub>0, Merck 99.9%) dissolved in 15ml of 2-propanol and monoethanolamine (HOCH<sub>2</sub>CH<sub>2</sub>NH<sub>2</sub>, Merck 99.9%) which was used as a stabilizer was added drop wise to yield a clear solution. The above solution was stirred for 1 hour. The molar ratios of Zinc Acetate dehydrate and Monoethanolamine were maintained at 1:1. The solution was then aged overnight to yield a homogeneous component. Various concentration of Graphene Oxide solution (1 wt.%, 3 wt. % and 5 wt.%) were prepared by dispersing the GO into distilled water through ultrasonication. The samples were then spin coated with graphene oxide and zinc solution at 3000 rpm for 30sec and annealed at 300° C for 10 mins for each deposition to remove organic residuals that might be present on the thin films.

# Growth of Nanocomposite ZnO thin films through hydrothermal method

Zinc nitrate hexahydrate  $(Zn(NO_3)_2 \cdot 5H_2O)$  and hexamethylenetetramine (HMTA),  $(C_6H_{12}N_4)$  purchased from Sigma-Aldrich were used as reagents. Nanocomposite ZnO-GO thin films were formed by immersing the prepared ZnO-GO thin films vertically in aqueous growth solution containing zinc nitrate hexahydrate and HMTA in 50ml double distilled water, inside the Teflon – lined autoclave at 90° C for 3 hours. The molar ratio of ZN/HMTA is 1:1. The obtained thin films were thoroughly washed with de-ionized water to remove any residual materials and then annealed at 350° C for 1 hour. The samples were named as S1, S2 and S3 respectively.

The morphology of ZnO-RGO nanocomposite thin films were examined with Field emission scanning electron microscopy (FESEM) and energy-dispersive X-ray spectroscopy (EDS) analysis were performed using FEI Quanta FEG 200. The structure of the thin film was analyzed by PANalytical'sX'Pert PRO with Cu Ka radiation ( $\lambda = 1.542$ Å). The functional group analysis of graphene oxide was studied using Fourier Transform Infrared Spectroscopy using ALPHA-T FT-IR Spectrometer. Optical absorption spectra were investigated using SHIMADZU UV-Vis–Spectrophotometer.



Fig.1 Illustration for preparation of ZnO-RGO nanocompositethin film through a hydrothermal process.

# **Results and discussion**

Fig.2 shows FESEM images of ZnO-RGO nanocomposite thin films (a-c) with different GO concentration. It is observed that the surface of GO is packed densely with ZnO nanoparticles. It is seen that as the GO concentration is increased from 1 wt. % to 5 wt. %, agglomeration of particles occurs which might be due to the increase in the GO concentration Fig.2 (d) shows the EDS analysis of the product. It indicates that the ZnO-RGO nanocompositethin films are composed of three elements: C, Zn and O and absence of other impurities.



Fig.2 Surface Morphology of ZnO-RGOnanocomposite thin films prepared by hydrothermal method with GO Concentration a) 1 wt. % b) 3 wt. % c) 5 wt. % and EDS spectra (d) of 5 wt. % GO in ZnO-RGONanocomposite thin films

The XRD pattern of GO is shown in fig 3 (a). The GO shows the diffraction peak at  $2\Theta = 11.3^{\circ}$ . The ZnO–RGOnanocomposite thin films are shown in fig 3 (b).



Fig.3 XRD pattern of (a) GO and (b) with GO Concentration a) 1 wt. % b) 3 wt. % c) 5 wt. %

The diffraction peak at  $32^{\circ}$ ,  $36^{\circ}$ ,  $48^{\circ}$ ,  $57^{\circ}$ ,  $63^{\circ}$  and  $68^{\circ}$  corresponds to (100), (002), (101), (102), (110), (103) and (112). There is no characteristic diffraction peak of GO observed indicating the reduction of GO to RGO by hydrothermal process and formation of high purity of ZnO film<sup>23</sup>. No diffraction peak of GO could also be due to relatively low content of GO in ZnO-RGOnanocomposite thin films<sup>24</sup>. It can be also observed that as the concentration of GO increases from 1 wt. % to 5 wt. %, the peak intensity reduces which could possibly due to the reduction of ZnO amount in the composite<sup>20</sup>.



Fig.4FTIR Spectra of GO

Fig. 4 shows the FTIR spectra of GO. Mainly GO has carboxyl and hydroxyl groups in it. The broad peak at 3107 cm<sup>-1</sup> represents O-H stretching vibrations. The peaks at 1579 cm<sup>-1</sup> and 1049 cm<sup>-1</sup> represents C=C stretching vibrations and C-O stretching vibrations<sup>25</sup>.



Fig.5 UV-visible spectra of the synthesized ZnO-RGO nanocomposite thin filmswith GO Concentration a) 1 wt. % b) 3 wt. % c) 5 wt. %

Fig. 5shows the UV-visible spectra of the synthesized ZnO-RGO nanocomposite thin films with various concentration of GO. The absorption edge of ZnO-RGO nanocomposite thin films hows a slight red-shift towards the higher wavelength with the increase of GO content which could probably due to the chemical bonding between ZnO and  $\mathrm{GO}^{26}$ .



Fig.6.Direct bandgap of ZnO-RGO nanocomposite thin films with GO Concentration a) 1 wt. % b) 3 wt. % c) 5 wt. % by using Tauc's plot

Tauc's plot of ZnO-RGOnanocomposites thin films with various concentration of GO is shown on Fig 6. The estimated band gaps values of the samples are about 3.33eV, 3.28eV and 3.0eV corresponding to 1 wt. %, 3 wt. % and 5 wt. % of GO. This indicates that there is a band gap narrowing of ZnO due to the introduction of GO in the matrix of ZnO nanoparticles<sup>27</sup> and the formation of Zn-O-C chemical bond in the composites<sup>28</sup>.

# Conclusion

In summary, we have prepared ZnO-RGOnanocomposite thin films by hydrothermal method. The effects of GO concentration on morphology, structural and optical proprieties are investigated. It is seen that the addition of GO does not change the morphology of ZnO thin films. The XRD patterns states that there is no diffraction peak of GO which could also be due to relatively low content of GO in nanocomposite. Futhermore, the bandgap of ZnO nanoparticles is decreased by addition of GO and slight red shift towards the higher wavelength could be investigated.

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